

WEST Search History

DATE: Friday, May 23, 2003

<u>Set Name</u>	<u>Query</u>	<u>Hit Count</u>	<u>Set Name</u>
side by side			result set
	<i>DB=USPT,PGPB,JPAB,EPAB,DWPI,TDBD; PLUR=YES; OP=ADJ</i>		
L6	L1 and (control\$5 same (UV or IR or wavelength or absorbance or refraction))	57	L6
L5	L4 and l3	0	L5
L4	((134/18 134/56R 134/902)!.CCLS. (438/906)!.CCLS.)	3193	L4
	<i>DB=USPT,JPAB,EPAB,DWPI; PLUR=YES; OP=ADJ</i>		
L3	L1 same (UV or IR or wavelength or absorbance or refraction)	43	L3
L2	L1 same (control\$5 with (UV or IR or wavelength or absorbance or refraction))	0	L2
L1	(clean\$3 or etch\$3 or remov\$3 or rins\$3 or treat\$3) same (substrate or semiconductor or wafer) same ((ammonium fluoride)or 'NH.sub.4 F')	1850	L1

END OF SEARCH HISTORY